A Multistimuli-Response Fluorescent Switch in the Solution and

Solid State Based on Spiro[fluorene-9,9' -xanthene] -

Spiropyran

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Scheme S1 The possible interactions of **SFX-2MCH** when **SFX-2SP** powder was exposed to excess gaseous HCl.



Figure S1 ¹H NMR spectrum of compound **3** in CDCl₃



Figure S2 ¹³C NMR spectrum of compound **3** in CDCl₃



Figure S3 HRMS spectrum of compound 3



Figure S4 ¹H NMR spectrum of compound **4** in DMSO- d_6



Figure S5 ¹³C NMR spectrum of compound 4 in DMSO-*d*₆



Figure S6 HRMS spectrum of compound 4



Figure S7 ¹H NMR spectrum of SFX-2SP in DMSO-*d*₆



Figure S8 ¹³C NMR spectrum of SFX-2SP in CDCl₃.



Figure S9 HRMS spectrum of SFX-2SP.





Figure S10. UV-vis and emission spectra of SPF, SP, SFX-2SP and SFX-2MC in EtOH.



Figure S11 The molar extinction coefficient at 557 nm for **SPF-2SP** in EtOH with different 365 nm irradiation time.



Figure S12(a) The absorption and (b) PL spectra of **SFX-2SP** (6 μ M) in EtOH-H₂O (9:1, v/v) with different metal ions (1mM). Insets: The pictures of corresponding solutions in ambient light.



Figure S13 The PL spectra of **SFX-2SP** solid with different 365 nm irradiation time.



Figure S14 Contact angle of the surface of the SFX-2SP film (a) before and (b) after

UV light irradiation.



Figure S15 The PL spectra of **SFX-2SP** solid with HCl fuming.



Figure S16 Application of information encryption and decryption with 1 wt% SFX-2SP-loaded PMMA film by UV irradiation and heat.



Figure S17 The molar extinction coefficient of **SPF-2SP** in PMMA -based film with different 365 nm irradiation time.



Figure S18 (a) UV-vis and (b) emission spectra of 1 wt% **SFX-2SP**-loaded PMMA film upon HCl and gaseous NH₃ fuming.

Entry	Irradiation time (min)	Absolute quantum yield
1	0	0.07
2	4	0.11
3	8	0.10

Table S1 The absolute quantum yield of solution in EtOH with increasing irradiation time.

Table S2 The absolute quantum yield of 1 wt% **SFX-2SP**-loaded PMMA film with increasing irradiation time.

Entry	Irradiation time (min)	Absolute quantum yield
1	0	0.04
2	2	0.14
3	4	0.16
4	6	0.17
5	10	0.16
6	20	0.15

Entry	Irradiation time (min)	fluorescence lifetime (ns)
1	0	2.568
2	0.5	2.235
3	1	2.206
4	2	2.116
5	4	2.099
6	6	2.090
7	8	2.102
8	12	2.104
9	16	2.097
10	20	2.133

Table S3 The fluorescence lifetime of 1 wt% **SFX-2SP**-loaded PMMA film with increasing irradiation time.

Table S4 The fluorescence lifetime of **SFX-2SP** solution in EtOH with increasing irradiation time.

Entry	Irradiation time (min)	fluorescence lifetime (ns)
1	0	4.099
2	1	3.592
3	2	3.476
4	4	2.255